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The 10th International Conference

Charged & Neutral Particles Channeling Phenomena

8-13 September 2024 Riccione (Rimini), Italy







Implementing Capillary Design for Reliable VHEE Beam Delivery

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Outline



2

- Very High Energy Electron (VHEE) for Radiotherapy
- Laser-plasma Acceleration (LPA) for VHEE
- Introducing I-LUCE Facility
- Plasma Module & Plasma Diagnostic
- Plasma Modelling in COMSOL Multiphysics



VHEE: For RT

3



Energy Range	~ 250 MeV	~ 250 MeV
Penetration Depth	High (deep- <u>seated</u> tumors)	High (deep- <u>seated</u> tumors)
Dose Distribution	Sharp dose fall-off (Bragg Peak)	Favorable dose distribution
Radiobiological Eff ectiveness	High due to dense ionization	Comparable to proton/ions in high energy range
Normal Tissue Sparing	Exellent, mínímal damage	Good, small penumbra, mínímal secondary products
Cost and Infrastructure	Hígh cost, large area	Low cost, ready to implement
Clinical Evidence	Growing (partially established)	Emerging (early studies)
Technology Availability	Límíted centers	Increasing with e-accelerators
Treatment Flexibility	High presision, less flexible sparing	Flexible (combination of electron § photon therapy)

Several Electron Beam Energies (all in MeV)

- LUCE



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VHEE: Toward Experimental Implementation via LPAs



VHEE can be generated using LPAs, which leverage plasma technology and intense laser pulses to propel charged particles to very high energies over short distances (via gas jets or discharge capillaries).



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4

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LPAs: Laser Wakefield Acceleration (LWFA)

LWFA Mechanism

Laser Pulse Injection:
A powerful laser pulse is directed into a plasma.

> Creation of Plasma Wake:

The high-intensity laser pulse generates a strong electric field in the plasma, known as the plasma wake.

Electron Displacement:

This electric field from the laser pulse pushes electrons away from their original positions in the plasma.

> Formation of Positive Charge Region:

This movement of electrons creates a region of positive charge because the heavier ions remain relatively stationary while the lighter electrons move away.

Electron Acceleration:

Electrons are accelerated as they ride the wake created by laser and gain energy as they move through these waves.

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Principal Acceleration Diagram



Electron Acceleration







T. Tajima, J. Dowson, Phys. Rev. Lett, 43 (1979)

Laser Electron Accelerator

T. Tajima and J. M. Dawson Department of Physics, University of California, Los Angeles, California 90024 (Received 9 March 1979)

An intense electromagnetic pulse can create a weak of plasma oscillations through the action of the nonlinear ponderomotive force. Electrons trapped in the wake can be accelerated to high energy. Existing glass lasers of power density 10^{18} W/cm² shone on plasmas of densities 10^{18} cm⁻³ can yield gigaelectronvolts of electron energy per centimeter of acceleration distance. This acceleration mechanism is demonstrated through computer simulation. Applications to accelerators and pulsers are examined.

W.P. Leemans et al., Phys. Rev. Lett, 113 (2014)

PRL 113, 245002 (2014)	Selected for a Viewpoint in Physics PHYSICAL REVIEW LETTE	R S 12 DECEMBER 2014
	G.	
Multi-GeV Ele	ctron Beams from Capillary-Discharg Laser Pulses in the Self-Trapping R	e-Guided Subpetawatt egime
W. P. Leemans, ^{1,2,*} A. J. Gonsal D. E. Mittelt ¹ Lawr ² Departme (Received 3 July 20	ives, ¹ HS. Mao, ¹ K. Nakamura, ¹ C. Benedetti, ¹ berger, ^{2,1} S. S. Bulanov, ^{2,1} JL. Vay, ¹ C. G. R. Gr ence Berkeley National Laboratory, Berkeley, Califor- mit of Physics, University of California, Berkeley, Ca 14; revised manuscript received 11 September 2014;	C. B. Schroeder, ¹ Cs. Tóth, ¹ J. Daniels, eddes, ¹ and E. Esarey ¹ mia 94720, USA difornia 94720, USA published 8 December 2014)
Multi-GeV electro rms divergence have of $\approx 7 \times 10^{17}$ cm ⁻³ , 1 allow the use of low beam energy. A deta regime of the guiding mode profile.	n beams with energy up to 4.2 GeV, 6% rms energy spi been produced from a 9-em-long capillary discharge w powered by laser pulses with peak power up to 0.3 PW. et laser power compared to unguided plasma structure iled comparison between experiment and simulation g and acceleration in the plasma structure to input intense	read, 6 pC charge, and 0.3 mrad aveguide with a plasma density Preformed plasma waveguides es to achieve the same electron indicates the sensitivity in this sity, density, and near-field laser
DOI: 10.1103/PhysRev	/Lett.113.245002	PACS numbers: 52.38.Kd



Acceleration Scheme: Laser Wakefield Acceleration (LWFA)

Wave Amplitude and Laser Pulse Length:

- > The amplitude of the wakefield (the electric field generated behind the laser pulse) depends on the length (vety short) and intensity of the laser pulse.
- Longer pulses generally excite larger wakefields.

Dependency on Plasma Wavelength:

> The maximum accelerating field that can be achieved is influenced by the plasma wavelength (λ_n) , which is related to the plasma density (n_e) .

Dependency on Plasma Density:

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6

- \triangleright A higher plasma density results in a shorter plasma wavelength.
- \succ Higher plasma density leads to stronger collective effects, enhancing the wakefield amplitude and the accelerating field.
- > Higher density plasmas support stronger wakefields, leading to more efficient acceleration

Regulation by Background Plasma Density:

- > The background plasma density effectively regulates the accelerating field.
- > The density determines the plasma wavelength, which affects the strength of the wakefield and the efficiency of electron acceleration.

«Plasma density controls the strength of the accelerating field» 10th International Conference, Charged & Neutral Particles Channeling Phenomena

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Accelerating field: $E [GV/m] \approx 96 (n_{p} [cm^{-3}])^{1/2}$

$E_0 = \frac{cm_e\omega_p}{c}$, $n_e = 2 \times 10^{17} \text{ cm}^{-3} \Rightarrow E_0 \approx 40 \text{ GV/m}$

Plasma wavelength:

$$\lambda_p \equiv \frac{2\pi c}{\omega_p} \approx 100 \,\mu \mathrm{m}$$
 $T_{pulse} \approx \frac{\lambda_p}{2\pi c} \approx 50 \,\mathrm{fs}$

Plasma frequency:

 $\omega_p = \sqrt{\frac{n_e \, e^2}{m_e \varepsilon_0}}$





I-LUCE at INFN-LNS (Laboratori Nazionali del Sud)





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7

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Mul LUCE I-LUCE (INFN - Laser indUCEd radiation production) Facility

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I-LUCE Facility: Plasma Source (Plasma-discharge Capillary)



A capillary is a small, narrow tube, often made of dielectric materials such as quartz, non-commercial plastic (VeroClear), sapphire, glass, or etc. that confines the plasma.



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9

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I-LUCE Facility: Plasma LAB (Direct Current Plasma Discharge)





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Plasma Diagnostic: Density Measurements



- Emission Spectroscopy: Studies the light emitted by atoms, etc. during transitions from higher to lower energy states.
- Broadening Mechanism: Natural, Doppler, and Collisional (Stark) broadenings, that can allow us to measure the electron density.



Plasma Diagnostic: Temperature Measurements



13 Intensity Ratios: Using the intensity ratios of different spectral lines to infer the electron temperature.



S. S. Harilal et al., 52, 3 (1998)

S. Arjmand et al., JINST, 18, P08003 (2023)

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Plasma Diagnostic: Temperature Measurements



HR Griem, Academic Press Inc, App. III (1974)

Plasma Density: $10^{17} cm^{-3}$ Temperature: 1 - 4 eV 14

Two mechanisms:

- > Ablation: Typically generated by intense laser pulse focused on solid target (in our case small amount of surface ablation), causing material to be ejected/melted from the surface.
- > Desorption: Refers to when atoms or molecules leave the surface of material without fully vaporizing the surface (the most dominant mechanism.

VeroClear ($C_5 O_2 H_8$): 82.92% Carbon 16.50% Oxvaen 0.57% Nitrogen due to impurity (78% in the air) ✓ Emitted

0 I, 0 II, 0 III, N I, N II, N III, C I, C II, C III

✓ Considerd

• OII (471.9803 nm) or NII (471.8377 nm) • O III (508.8922 nm) or N III (454.970 nm)



31









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Plasma Diagnostic: Temperature Measurements



15 NIST Database (<u>https://physics.nist.gov/PhysRefDa</u>	ata/ASD/levels_form.h
Oxygen Element Spectroscopic Data	
arameter	Value
Wavelength of O II	471.9803 (nm)
Wavelength of O III	508.492 (nm)
Statistical Weight of O II	1
Statistical Weight of O III	1
Oscillator Strength of O II	8.57 ×10 ⁴ (DI)
Dscillator Strength of O III	6.15×10^{6} (DI)
Lower-level and Upper-level Angular Momentum Quantum Number of O II	$\frac{3}{2}, \frac{3}{2}$
Lower-level and Upper-level Angular Momentum Quantum Number of O III	2, 2
Excitation Energy of O II	2.62 (eV)
Excitation Energy of O III	2.43 (eV)
: Ionization Energy of Lower State of O II	35.11730 (eV)
Jumber of Electrons Lost by O II	1
Nitrogen Element Spectroscopic Data	
ameter	Value
Vavelength of N II	471.8377 (nm)
/avelength of N III	453.970 (nm)
atistical Weight of N II	1
atistical Weight of N III	1
scillator Strength of N II	3.02 ×10 ⁷ (DI)
Oscillator Strength of N III	5.71×10^7 (DI)
ower-level and Upper-level Angular Momentum Quantum Number of N II	4, 4
ower-level and Upper-level Angular Momentum Quantum Number of N III	$\frac{1}{2}, \frac{1}{2}$
Excitation Energy of N II	2.62 (eV)
Excitation Energy of N III	2.77 (eV)
Ionization Energy of Lower State of N II	29.6013 (eV)
Jumber of Electrons Lost by N II	1
Physical Constants	
meter	Value
Hydrogen Ionization Energy	13.6 (eV)
Vacuum Permittivity	$8.85 \times 10^{-12} (\mathrm{F}\mathrm{m}^{-1})$
Bohr Radius	$5.2917724 \times 10^{-11}$ (m)
Electron Mass	9.10938×10^{-31} (kg)
lectron Charge	1.602×10^{-19} (C)
educed Planck Constant	$1.05457 \times 10^{-34} \text{ (J s)}$
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024



Plasma Diagnostic: Temperature Simulation (O & N Ions)

6.0E+01



520



VeroClear (C₅O₂H₈): 82.92% Carbon 16.50% Oxygen 0.57% Nitrogen due to impurity

NIST Database (https://physics.nist.gov/PhysRefData/ASD/levels_form.html)





Nitrogen II

Saha/LTE Spectrum for mixture C:82.92%+N:0.579999999999999993%+O:16.50% $T_0 = 2.32$ eV, $N_0 = 6.8e+17$ cm⁻³, Resolution = 1000. Total of 365 lines; Ion abundances are given in parentheses --- N II (5.4e-3)



Oxygen II

Saha/LTE Spectrum for mixture C:82.92%+N:0.5799999999999983%+O:16.50% $T_{e} = 2.34 \text{ eV}$, $N_{e} = 6.8e+17 \text{ cm}^{-3}$, Resolution = 1000. Total of 365 lines; lon abundances are given in parentheses



Oxygen III

Wavelength (nm)

500

Nitrogen III

T_e = 2.32 eV, N_e = 6.8e+17 cm⁻³, Resolution = 1000. Total of 365 lines; lon abundances are given i

Saha/LTE Spectrum for mixture C:82.92%+N:0.57999999999999983%+O:16.50%

narontheeae

460

480

1.8E-02

1.6E=02

1.4E-02

1.2E-02

1.0E-02

8.0E-03

6.0E-03

4.0E-03

2.0E-03

Saha/LTE Spectrum for mixture C:82.92%+N:0.5799999999999983%+O:16.50% T_{g} = 2.34 eV, N_{g} = 6.8e+17 cm 3 , Resolution = 1000. Total of 365 lines; Ion abundances are given in narchhead



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Particle-particle reaction (excitations, ionisations, chrage exchange) Reactions (ionisations, recombinations) on cathode and capillary surface.

> Ar collision processes Ar: Atom, Ar*: Excited Argon, Ar+: Ionized Argon

1) $e + Ar => e + Ar^*$ (Elastic Scattering) 2) $e + Ar => e + Ar^* => e + Ar + photon (Excitation)$ 3) $e + Ar^* => e + Ar (Superelastic)$ 4) e + Ar => 2e + Ar + (Ionization)5) $e + Ar^* => 2e + Ar + (Ionization)$ 6) $Ar^* + Ar^* => e + Ar + Ar + (Penning Ionization)$ 7) $Ar^* + Ar => Ar + Ar (Metastable Quenching)$

Surface Reactions:

Ar atoms or metastable atoms intercat with the wall and transition back to ground state

1) Ar + => Ar

https://www.comsol.com/ 2) Ar* => Ar



18

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B. Radjenovic et al., Acta Physica Slovaca 63(3):105-205





A capillary of length L = 3 cm and diameter of d = 1 and 2 mm, filled with Argon at the pressure p = 7.5 Torr (10 mbar) is considered, to generate a plasma in the range of 10^{17} cm⁻³.

- From the Argon Paschen curve, the minimum voltage required to initiate gas breakdown results V0 ~ 800 V for a capillary of length L = 3 cm, at the pressure p = 7.5 Torr (10 mbar).
- > At voltage lower than the one needed to initiate the breakdown, no discharge occurs (the electron density is lower than the initial one, fixed at $n_{ei} = 10^7$ cm⁻³).
- > When the applied voltage is higher than the breakdown one, the electron density starts to increase.
- > All values taken in the simulation time $t = 2 \mu s$, at which the density results almost stationary.

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Electron Density Vs Applied Voltage





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19

^m 0.03

0.028

0.026

0.024

0.022

0.02

0.018

0.016

0.014

0.012

0.01

0.008

0.006

0.004

0.002

cm)

က

Longitudinal axis of the capillary (L





3cm/long-2mm/diameter 10 mbar, 10 kV, 2 μs With Argon gas



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Plasma Stability: Shot-to-shot Stability

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Plasma Stability: Stabilization by a Laser Technique



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